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In the United States Patent and Trademark Office

lication of:

Haley, et al

RADIATION-SENSITIVE COMPOSITION CONTAINING A RESOLE RESIN, A NOVOLAC RESIN, AN INFRARED ABSORB-ER AND A TRIAZINE AND USE THEREOF IN LITHOGRAPHIC PRINTING PLATES

Serial No. 212,434

Filed 14 March 1994

Group Art Unit: 1507

Examiner: L. Weiner

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Alfred P. Lorenzo

22.503 Reg. No. Ignature

Date of Signature

Honorable Commissioner of Patents and Trademarks Washington, D.C. 20231

Transmitted herewith is a Response in the above-identified application:

No additional fee is required.
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F	FIRST PRESENTATION OF MULTIPLE DEPENDENT CLAIM						\$	
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Any patent application processing fees under 37 CFR 1.17.

(For Extensions of Time and other Petitions to the Commissioner)

Alfred P. Lorenzo/mla

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Attorney for Applicants

Registration No. 22,503

#6/B 68529APL 3-95



United States Patent and Trademark Office

Application of:

Neil F. Haley, et al

RADIATION-SENSITIVE
COMPOSITION CONTAINING A
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Signat

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Sir:

AMENDMENT UNDER 37 C.F.R. 1.111

In response to the Office Action of October 26, 1994, please amend the above-identified application as follows:

In the Specification:

Page 1, line 12, after Corbiere insert --, abandoned in favor of continuation application Serial No. 205,125, filed March 1, 1994, which issued on December 13, 1994, as United States Patent No.

5,372,907. ==

REMARKS

Reconsideration of this application is respectfully requested for the reasons which follow.

On page 1 of the specification, reference to the copending application has been updated.

The rejection of claims 1-27 under 35 U.S.C. 103 as unpatentable over Garth in view of Stahlhofen and Newman is respectfully traversed.

The invention disclosed and claimed by Applicants requires the presence of four essential

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